Atmospheric Chemistry of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H: Reaction with Cl Atoms and OH Radicals, Degradation Mechanism, and Global Warming Potentials

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Fourier transform infrared (FTIR) smog chamber techniques were used to measure $k(Cl + CF_3CFHCF_2-OCF_3) = (4.09 \pm 0.42) \times 10^{-17}$, $k(OH + CF_3CFHCF_2OCF_3) = (1.43 \pm 0.28) \times 10^{-15}$, $k(Cl + CF_3CFHCF_2-OCF_2H) = (6.89 \pm 1.29) \times 10^{-17}$, and $k(OH + CF_3CFHCF_2OCF_2H) = (1.79 \pm 0.34) \times 10^{-15}$ cm³ molecule⁻¹ s⁻¹ in 700 Torr of N₂/O₂ diluent at 296 K. The atmospheric lifetimes of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂-OCF₂H are approximately 40 and 32 years, respectively. Chlorine atom-initiated oxidation of CF₃CFHCF₂-OCF₃ and CF₃CFHCF₂OCF₂H gives CF₃C(O)F in molar yields of 82 ± 5% and 96 ± 6%, respectively. The 100-year time horizon global warming potentials of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H relative to CO₂ are 4530 and 4340. Results are discussed with respect to the atmospheric chemistry of hydrofluoroethers.

1. Introduction

Recognition of the adverse environmental impact of chlorofluorocarbon (CFC) and halon release into the atmosphere^{1,2} has led to an international effort to replace these compounds with environmentally acceptable alternatives. Hydrofluoroethers (HFEs) are a class of compounds which have been developed to replace CFCs and halons in applications such as the cleaning of electronic equipment, heat transfer, carrier fluids for lubricant deposition, and fire suppression. Prior to their large-scale industrial use, an assessment of the atmospheric chemistry, and hence environmental impact, of HFEs is needed. To address this need, the atmospheric chemistry of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H was investigated. Smog chamber/FTIR techniques were used to determine the following parameters for these compounds: (i) kinetics of reactions with chlorine atoms, (ii) kinetics of reactions with hydroxyl radicals, (iii) infrared spectra, (iv) atmospheric lifetimes, and (v) global warming potentials. Results are reported herein.

2. Experimental Section

All experiments were performed in a 140-L Pyrex reactor interfaced to a Mattson Sirus 100 FTIR spectrometer.³ The reactor was surrounded by 22 fluorescent blacklamps (GE F40BLB) which were used to photochemically initiate the experiments.

Cl atoms were generated by the photolysis of Cl₂

$$Cl_2 + hv \rightarrow 2Cl$$
 (1)

OH radicals were generated by UV irradiation of CH₃ONO/ NO/air mixtures

$$CH_3ONO + hv \rightarrow CH_3O + NO$$
 (2)

$$CH_3O + O_2 \rightarrow HCHO + HO_2 \tag{3}$$

$$HO_2 + NO \rightarrow OH + NO_2$$
 (4)

Reactant and product concentrations were monitored using in situ FTIR. IR spectra were derived from 32 coadded interferograms with a spectral resolution of 0.25 cm⁻¹ and an analytical path length of 27.1 m. Reference spectra were acquired by expanding known volumes of reference compounds into the chamber.

Experiments were performed at 296 ± 2 K in 700 Torr of N₂/O₂ diluent. All reagents except CH₃ONO were obtained from commercial sources at purities greater than 99%. The samples of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H were supplied by Great Lakes Chemical Corporation. Ultrahigh purity nitrogen, oxygen, and synthetic air diluent gases were used as received. CH₃ONO was prepared by the dropwise addition of concentrated H₂SO₄ to a saturated solution of NaNO₂ in methanol and was devoid of any detectable impurities using FTIR analysis.

In smog chamber experiments, the unwanted loss of reactants, reference compounds and products via photolysis, chemistry occurring in the dark, and heterogeneous reactions have to be considered. The reactant and reference compounds used in the present work (CF₃CFHCF₂OCF₃, CF₃CFHCF₂OCF₂H, C₂H₄, C₂H₂, CF₃CF₂H, and CF₃CH₃) do not absorb at wavelengths above the Pyrex cutoff (>300 nm). Photolytic loss of these compounds will not be a complication in the present work. Control experiments were performed in which reactant and product mixtures obtained after UV irradiation were allowed to stand in the dark in the chamber for 30 min. There was no observable (<2%) loss of reactants or products, showing that heterogeneous reactions are not a significant complication in the present experiments. Analysis of the IR spectra was achieved through a process of spectral stripping, in which small fractions of the reference spectrum were subtracted incrementally from

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the sample spectrum. The concentration of reactant and reference compounds could be determined with a precision of $\pm 1\%$ of their initial concentrations.

The relative rate method is a well-established and widely used procedure for measuring the reactivity of Cl atoms and OH radicals with organic compounds.⁴ Kinetic data are derived by monitoring the loss of a reactant compound (CF₃CFHCF₂OCF₃ or CF₃CFHCF₂OCF₂H in the present work) relative to one or more reference compounds. The decays of the reactant and reference are then plotted using the following expression

$$Ln\left(\frac{[\text{Reactant}]_{t_0}}{[\text{Reactant}]_t}\right) = \frac{k_{\text{Reactant}}}{k_{\text{Reference}}}Ln\left(\frac{[\text{Reference}]_{t_0}}{[\text{Reference}]_t}\right)$$

where $[\text{Reactant}]_{t_0}$, $[\text{Reactant}]_t$, $[\text{Reference}]_{t_0}$, and $[\text{Reference}]_t$ are the concentrations of reactant and reference at times t_0 and t, and k_{Reactant} and $k_{\text{Reference}}$ are the rate constants for the reactions of Cl atoms or OH radicals with the reactant and reference.

The photolysis of CH₃ONO is the most convenient and widely used source of OH radicals in relative rate studies. CH₃ONO itself reacts with OH at a moderate rate (approximately 3 \times 10^{-13} cm³ molecule⁻¹ s⁻¹⁵), scavenges OH radicals, and makes the loss of a less reactive compound (e.g., CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H) small and difficult to measure. In the present work, we have employed a variation on the typical relative rate method in which the loss of the reactant (CF3-CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H) was monitored indirectly by observing the formation of its oxidation product (CF₃C(O)F). Large initial concentrations of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H (0.74-2.18 Torr) were used to facilitate monitoring of the CF₃C(O)F product resulting from small (<0.2%) consumptions of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂-OCF₂H. It should be stressed that an accurate determination of the initial reactant concentrations is vital to this variation of the relative rate method.

3. Results

3.1. Cl Atom Kinetics. Relative rate experiments were performed to measure the rates of reaction of Cl atoms with CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H. The results are shown in Figure 1. Linear least-squares analyses of the data in Figure 1 give $k_5/k_7 = 0.163 \pm 0.010$, $k_5/k_8 = 1.14 \pm 0.09$, $k_6/k_7 = 0.253 \pm 0.019$, and $k_6/k_8 = 2.07 \pm 0.17$. Using literature values of $k_7 = (2.5 \pm 0.2) \times 10^{-16.6}$ and $k_8 = (3.6 \pm 0.2) \times 10^{-17.7}$ gives the following values: $k_5 = (4.08 \pm 0.41) \times 10^{-17.7}$ and $(4.10 \pm 0.39) \times 10^{-17.7}$ cm³ molecule⁻¹ s⁻¹. The fact that experiments using different references give indistinguishable results provides confidence in our results. We choose to quote final values of $k_5 = (4.09 \pm 0.42) \times 10^{-17.7}$ and $k_6 = (6.89 \pm 1.29) \times 10^{-17.7}$ cm³ molecule⁻¹ s⁻¹, which are the averages of the individual determinations with error limits which encompass the extremes of the individual determinations.

 $Cl + CF_3CFHCF_2OCF_3 \rightarrow products$ (5)

 $Cl + CF_3CFHCF_2OCF_2H \rightarrow products$ (6)

 $Cl + CF_3CF_2H \rightarrow products$ (7)

 $Cl + CF_3CH_3 \rightarrow products$ (8)

The value of $k_5 = (4.09 \pm 0.42) \times 10^{-17}$ measured in the present work is consistent with the upper limit of $k_5 < 7 \times 10^{-17}$

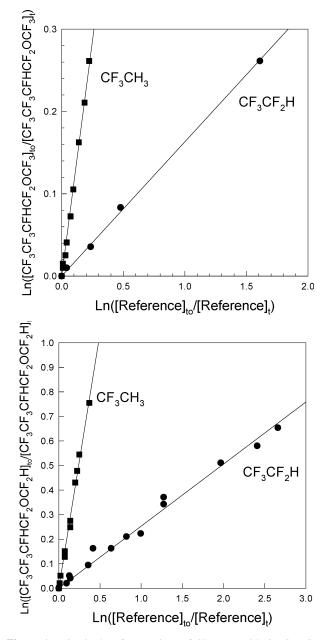


Figure 1. Kinetic data for reactions of Cl atoms with CF_3CFHCF_2 -OCF₃ (top) and $CF_3CFHCF_2OCF_2H$ (bottom).

 10^{-16} cm³ molecule⁻¹ s⁻¹ reported by Oyaro et al.⁸ There are no literature data for k_6 to compare with our results. The reactivity of Cl atoms toward CF₃CFHCF₂OCF₃ is indistinguishable, within the experimental uncertainties, from that toward CF₃CFHCF₃ ($k_{Cl+CF3CFHCF3} = (4.5 \pm 1.2) \times 10^{-17} \text{ cm}^3$ molecule $^{-1}$ s $^{-1}$ ⁹). Interestingly, the reactivity of Cl atoms toward CF₃CFHCF₂OCF₂H measured in the present work is indistinguishable, within the experimental uncertainties, from that of the sum of CF₃CFHCF₃ and CF₃OCF₂H: $(4.5 \pm 1.2) \times 10^{-17}$ $+ (2.3 \pm 0.3) \times 10^{-17} = (6.8 \pm 1.5) \times 10^{-17} \text{ cm}^3 \text{ molecule}^{-1}$ s⁻¹.^{9,10} The simplest explanation for the experimental observations is that the reactivities of the two C-H bonds in CF₃CFHCF₂OCF₂H are independent and additive. The simple kinetic arguments presented here would suggest that approximately 30% of the reaction of Cl atoms with CF₃CFHCF₂-OCF₂H proceeds via attack on the terminal C-H bond with the remaining approximately 70% of the reaction occurring at the secondary site.

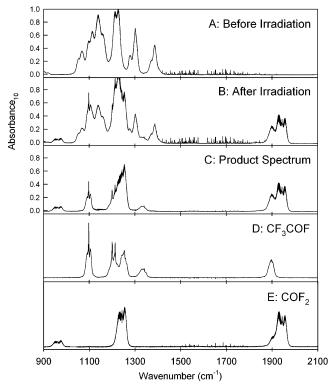


Figure 2. IR spectra obtained before (panel A) and after (panel B) a 12-min irradiation of a mixture containing 10.7 mTorr CF₃CFHCF₂-OCF₂H, 8.4 Torr Cl₂, and 21 Torr O₂ in 700 Torr of N₂ diluent. Subtraction of features attributable to CF₃CFHCF₂OCF₂H gives the product spectrum shown in panel C. Reference spectra of CF₃COF and COF₂ are shown in panels D and E.

3.2. Products of Cl Atom-Initiated Oxidation. To elucidate the atmospheric oxidation mechanism of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H, experiments were performed using mixtures of 10 mTorr of either CF₃CFHCF₂OCF₃ or CF₃CFHCF₂-OCF₂H, 0.5-8.4 Torr of Cl₂, and 21 Torr of O₂ in 700 Torr of N_2 diluent. As shown in Figure 2, $CF_3C(O)F$ and COF_2 were observed as major oxidation products in these experiments. Figure 3 shows plots of the observed formation of $CF_3C(O)F$ versus the loss of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H. Variation of [Cl₂] over a factor of 20 had no observable effect on the $CF_3C(O)F$ yield, suggesting that the present work is free from complications arising from the reaction of Cl₂ with radical species in the system. The lines through the data in Figure 3 give molar yields of CF₃C(O)F of 82 \pm 5 and 96 \pm 6% in the oxidation of CF3CFHCF2OCF3 and CF3CFHCF2OCF2H, respectively. A molar yield of COF_2 of 192 \pm 15% in the oxidation of CF₃CFHCF₂OCF₂H was also determined, while significant curvature in the COF2 yield was found in the oxidation of CF₃CFHCF₂OCF₃. IR product features consistent with the formation of CF₃OOCF₃ were observed in the CF₃-CFHCF₂OCF₃ experiments, but not in the CF₃CFHCF₂OCF₂H experiments. Finally, there was evidence in the IR product spectra and small amounts of a trioxide product in the CF₃-CFHCF₂OCF₃ experiments, but not in experiments involving CF₃CFHCF₂OCF₂H.

The simplest mechanism which explains the experimental observations is given immediately following for CF_3CFHCF_2 -OCF₃ (the • symbol indicates the position of the radical center):

 $Cl + CF_{3}CFHCF_{2}OCF_{3} \rightarrow CF_{3}CF(\bullet)CF_{2}OCF_{3} + HCl$ $CF_{3}CF(\bullet)CF_{2}OCF_{3} + O_{2} \rightarrow CF_{3}CF(OO\bullet)CF_{2}OCF_{3}$

$$2CF_{3}CF(OO\bullet)CF_{2}OCF_{3} \rightarrow 2CF_{3}CF(O\bullet)CF_{2}OCF_{3} + O_{2}$$

$$CF_{3}CF(O\bullet)CF_{2}OCF_{3} \rightarrow CF_{3}C(O)F + CF_{3}OCF_{2}(\bullet)$$

$$CF_{3}OCF_{2}(\bullet) + O_{2} \rightarrow CF_{3}OCF_{2}OO(\bullet)$$

$$2CF_{3}OCF_{2}OO(\bullet) \rightarrow 2CF_{3}OCF_{2}O(\bullet) + O_{2}$$

$$CF_{3}OCF_{2}O(\bullet) \rightarrow CF_{3}O(\bullet) + COF_{2}$$

$$CF_{3}O(\bullet) + CF_{3}O(\bullet) \rightarrow CF_{3}OOCF_{3}$$

CF₃CFHCF₂OCF₂H will follow a similar mechanism except that the penultimate step gives a CHF₂O radical instead of a CF₃O radical. In contrast to the behavior of CF₃O radicals, CHF₂O radicals react rapidly with O₂. Hence, there is no possibility of the formation of dioxides (ROOR) or trioxides (ROOOR) in the CF₃CFHCF₂OCF₂H system. Abstraction of the secondary hydrogen in CF₃CFHCF₂OCF₂H will result in the formation of one molecule of CF₃C(O)F by the reactions outlined here. Abstraction of the primary hydrogen will lead to the formation of CF₃CFHO radicals, 97% of which under the present experimental conditions (21 Torr O₂) will decompose via C–C

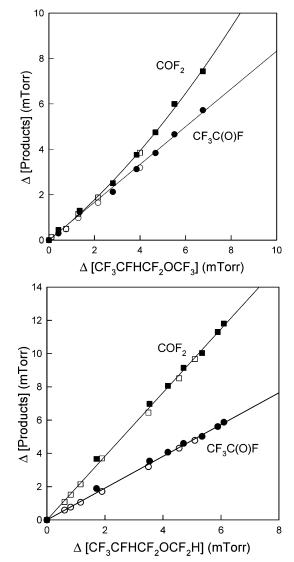


Figure 3. Formation of COF_2 (squares) and $CF_3C(O)F$ (circles) following UV irradiation of mixtures of 10 mTorr of either $CF_3CFHCF_2-OCF_3$ or $CF_3CFHCF_2OCF_2H$, 0.5 Torr (open symbols) or 8.4 Torr (filled symbols) of Cl_2 , and 21 Torr of O_2 , in 700 Torr of N_2 .

bond scission and will not form CF₃C(O)F.¹¹ The fact that the yield of CF₃C(O)F observed following the Cl atom-initiated oxidation of CF₃CFHCF₂OCF₂H is 96 \pm 6% shows that the branching ratio of abstraction of the secondary hydrogen in the reaction of Cl atoms with CF₃CFHCF₂OCF₂H is less than 10%. This result is at odds with the conclusion based upon kinetic arguments at the end of section 3.1. Such a disagreement highlights the difficulty in drawing quantitative mechanistic conclusions from such kinetic arguments.

It is interesting to note that $CF_3C(O)F$ and COF_2 are formed in the CF₃CFHCF₂OCF₂H system in yields which are indistinguishable from 100 and 200%, respectively, whereas in the CF₃-CFHCF₂OCF₃ experiments, the yields are both slightly less than 100%. The most likely explanation of this observation lies in the formation of small amounts of the trioxide CF₃CF- $(OOOCF_3)CF_2OCF_3$ from the reaction of CF₃O radicals with the $CF_3CF(OO\bullet)CF_2OCF_3$ peroxy radical. No such possibility exists in the experiments involving CF₃CFHCF₂OCF₂H. The observed curvature in the COF2 yield in the CF3CFHCF2OCF3 system, evident in Figure 3A, can be explained by the heterogeneous decomposition of CF₃OH to give COF₂ and HF. CF₃O radicals formed during the oxidation of CF₃CFHCF₂OCF₃ can abstract an H-atom from hydrogen-containing species (e.g., CF3-CFHCF₂OCF₃, HO₂) to give CF₃OH. IR features attributable to CF₃OH were observed in the product spectra. CF₃OH decomposes slowly in the chamber to give COF₂ and HF. The decomposition of CF₃OH augments the formation of COF₂ in the system leading to the curvature in the COF_2 yield plot.

The experiments described in the preceding paragraph were performed in the absence of NO. A limited number of experiments were performed with added NO in the system. Unfortunately, the loss of $CF_3CFHCF_2OCF_3$ in such experiments was too small (because of the competing reaction of Cl atoms with NO) to enable a reliable determination of the $CF_3C(O)F$ yield.

3.3. OH Radical Kinetics. For the purposes of quality control, a measurement of $k(OH + CF_3CFHCF_3)$ was performed prior to the study of CF_3CFHCF_2OCF_3 and CF_3CFHCF_2OCF_2H. Relative rate experiments were performed to measure $k(OH + CF_3CFHCF_3)$ using CF_3CFHCF_3/CH_3ONO/C_2H_4 and CF_3-CFHCF_3/CH_3ONO/C_2H_2 mixtures in 700 Torr of air diluent at 296 K. UV irradiation of CH_3ONO is a convenient source of OH radicals in the laboratory. After their formation in the chamber, the OH radicals will react with either the reactant (CF_3-CFHCF_3) or the reference (C_2H_4 or C_2H_2).

 $OH + CF_3CFHCF_3 \rightarrow products$ (9)

 $OH + C_2H_4 \rightarrow products$ (10)

$$OH + C_2H_2 \rightarrow products$$
 (11)

Loss of the reference compounds was monitored directly using their characteristic features in the IR region at 700–900 cm⁻¹. The loss of CF₃CFHCF₃ was measured indirectly by monitoring the formation of its oxidation product, CF₃C(O)F. It has been established previously that oxidation of CF₃CFHCF₃ gives CF₃C(O)F in 100% yield.⁹ Figure 4A shows the loss of CF₃-CFHCF₃ versus those of C₂H₄ and C₂H₂ observed in our experiments. The lines through the data are linear least-squares fits which give $k_9/k_{10} = (1.88 \pm 0.16) \times 10^{-4}$ and $k_9/k_{11} =$ $(2.20 \pm 0.18) \times 10^{-3}$. These relative rate data can be placed upon an absolute basis using literature values of $k_{10} = (8.66 \pm 0.38) \times 10^{-12}$ ¹² and $k_{11} = (8.5 \pm 1.0) \times 10^{-13}$ ¹³ to give independent determinations of $k_9 = (1.62 \pm 0.16) \times 10^{-15}$ and

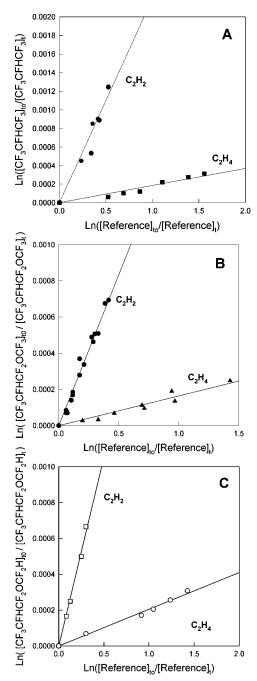


Figure 4. Kinetic data for reaction of OH radicals with CF_3CFHCF_3 (panel A), $CF_3CFHCF_2OCF_3$ (panel B), and $CF_3CFHCF_2OCF_2H$ (panel C).

 $(1.87 \pm 0.27) \times 10^{-15}$ cm³ molecule⁻¹ s⁻¹. We choose to quote a final value which is the average of the individual determinations with error limits which encompass the extremes of the individual determinations. Hence, $k(OH + CF_3CFHCF_3) = (1.75 \pm 0.39) \times 10^{-15}$ cm³ molecule⁻¹ s⁻¹. This result is in good agreement with the recommended¹⁴ literature value of $k(OH + CF_3CFHCF_3) = (1.7 \pm 0.2) \times 10^{-15}$ cm³ molecule⁻¹ s⁻¹, providing confidence in the experimental methodology.

The kinetics of the reactions of OH radicals with CF₃CFHCF₂-OCF₃ and CF₃CFHCF₂OCF₂H were studied using the method described in the preceding paragraph. The results are shown in Figure 4B,C. The loss of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂-OCF₂H was inferred from the observed formation of CF₃C-(O)F. As discussed in section 3.2, the Cl atom-initiated oxidation of CF₃CFHCF₂OCF₃ gives CF₃C(O)F in a yield of $82 \pm 5\%$. The reactions of Cl atoms and OH radicals with CF₃CFHCF₂- OCF₃ proceed via the same mechanism: hydrogen atom abstraction. It is reasonable to expect that the products of Cl atom-initiated oxidation of CF₃CFHCF₂OCF₃ will be identical to those of OH radical-initiated oxidation. Consequently, the CF₃CFHCF₂OCF₃ loss in the OH kinetic experiments can be estimated using the $CF_3C(O)F$ yield data given in section 3.2. There is one difference between the Cl atom and OH radical experiments which deserves discussion. The experiments described in section 3.2 were performed in the absence of NO, while the OH kinetic experiments were performed in the presence of NO. When NO is present, the fate of CF₃O radicals will be a reaction with NO to give COF₂ and FNO.¹⁵ Formation of trioxide via the addition of CF₃O to CF₃CF(OO•)CF₂OCF₃ radicals will not occur. Hence, the yield of CF₃C(O)F is expected to increase to 100%. Consistent with this expectation, we chose to assume a CF₃C(O)F yield from the OH radical-initiated oxidation of CF₃CFHCF₂OCF₃ of 100%. The data for CF₃-CFHCF₂OCF₂H shown in Figure 4C were determined using a molar yield of CF₃C(O)F of 100% (consistent with the results reported in section 3.2).

$$OH + CF_3CFHCF_2OCF_3 \rightarrow products$$
 (12)

$$OH + CF_3 CFHCF_2 OCF_2 H \rightarrow products$$
 (13)

The lines through the data in Figure 4B,C are linear leastsquares fits which give $k_{12}/k_{10} = (1.65 \pm 0.32) \times 10^{-4}$, $k_{12}/k_{11} = (1.67 \pm 0.24) \times 10^{-3}$, $k_{13}/k_{10} = (2.05 \pm 0.30) \times 10^{-4}$, and $k_{13}/k_{11} = (2.11 \pm 0.32) \times 10^{-3}$. These relative rate data can be placed upon an absolute basis using literature values of $k_{10} = (8.66 \pm 0.38) \times 10^{-12}$ and $k_{11} = (8.5 \pm 1.0) \times 10^{-13}$ 13 to give independent determinations of $k(OH + CF_3CFHCF_2-OCF_3) = (1.43 \pm 0.28) \times 10^{-15}$ and $(1.42 \pm 0.26) \times 10^{-15}$ and $k(OH + CF_3CFHCF_2OCF_2H) = (1.78 \pm 0.27) \times 10^{-15}$ and $(1.79 \pm 0.34) \times 10^{-15}$ cm³ molecule⁻¹ s⁻¹. We choose to quote final values which are averages of the individual determinations with error limits which encompass the extremes of the individual determinations. Hence, $k(OH + CF_3CFHCF_2-OCF_3) = (1.43 \pm 0.28) \times 10^{-15}$ and $k(OH + CF_3CFHCF_2-OCF_3) = (1.43 \pm 0.28) \times 10^{-15}$ and $k(OH + CF_3CFHCF_2-OCF_3) = (1.43 \pm 0.28) \times 10^{-15}$ and $k(OH + CF_3CFHCF_2-OCF_3) = (1.43 \pm 0.28) \times 10^{-15}$ and $k(OH + CF_3CFHCF_2-OCF_3) = (1.43 \pm 0.28) \times 10^{-15}$ and $k(OH + CF_3CFHCF_2-OCF_3) = (1.43 \pm 0.28) \times 10^{-15}$ and $k(OH + CF_3CFHCF_2-OCF_3) = (1.43 \pm 0.28) \times 10^{-15}$ and $k(OH + CF_3CFHCF_2-OCF_2H) = (1.79 \pm 0.34) \times 10^{-15}$ cm³ molecule⁻¹ s⁻¹.

We can compare our determination of $k(OH + CF_3CFHCF_2-OCF_2H) = (1.79 \pm 0.34) \times 10^{-15}$ with the measurement of $k(OH + CF_3CFHCF_2OCF_2H) = (1.69 \pm 0.26) \times 10^{-14}$ cm³ molecule⁻¹ s⁻¹ by Oyaro et al.⁸ For reasons which are unclear, Oyaro et al.⁸ report a rate constant which is a factor of 9 greater than that observed in the present work.

In section 3.1, we concluded that the reactivity of Cl atoms toward the two C–H bonds in CF₃CFHCF₂OCF₂H is independent and additive. If one assumes that the reactivity toward OH radicals displays similar behavior, the literature values of $k(OH + CF_3CFHCF_3) = (1.7 \pm 0.2) \times 10^{-15}$ and $k(OH + CF_3OCF_2H) = (4.9 \pm 1.0) \times 10^{-16\,14}$ can be used to estimate $k(OH + CF_3CFHCF_2OCF_2H) \approx k(OH + CF_3CFHCF_3) + k(OH + CF_3CFHCF_2OCF_2H) \approx (2.2 \pm 0.3) \times 10^{-15}$ cm³ molecule⁻¹ s⁻¹. Our value of $k(OH + CF_3CFHCF_2OCF_2H) = (1.79 \pm 0.34) \times 10^{-15}$ cm³ molecule⁻¹ s⁻¹ is consistent with this estimation, providing confidence in the present methodology.

3.4. Atmospheric Lifetimes. The values of $k(OH + CF_3-CFHCF_2OCF_3)$ and $k(OH + CF_3CFHCF_2OCF_2H)$ can be used to provide estimates of the atmospheric lifetimes of CF_3CFHCF_2-OCF_3 and CF_3CFHCF_2OCF_2H. Assuming an atmospheric lifetime for CH_3CCl_3 with respect to the reaction with OH radicals of 5.7 years¹⁶ and a rate constant for the CH_3CCl_3 + OH reaction of 1.0×10^{-14} cm³ molecule⁻¹ s^{-1 14} leads to

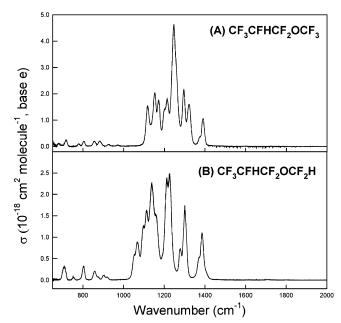


Figure 5. IR spectra of $CF_3CFHCF_2OCF_3$ (panel A) and $CF_3CFHCF_2-OCF_2H$ (panel B).

estimates of the atmospheric lifetimes of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H of 40 and 32 years, respectively. The optimal temperature for such a scaling analysis is 272 K¹⁷ (rather than 295 K used here), but we do not have any data for k_1 at 272 K. By analogy to other HFEs, the temperature dependence of reaction 1 is expected to be similar to that for the reaction of OH radicals with CH₃CCl₃. Hence, the use of 295 K rather than 272 K is not expected to have any material impact on the estimated atmospheric lifetime.

3.5. IR Spectra and Global Warming Potentials. The IR spectra of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H recorded in 700 Torr of air diluent at 296 K are shown in Figure 5. The integrated cross-sections $(650-1500 \text{ cm}^{-1})$ are $(4.28 \pm 0.22) \times 10^{-16}$ and $(3.64 \pm 0.19) \times 10^{-16} \text{ cm}^2$ molecule⁻¹ cm⁻¹ for CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H, respectively. Our measured intensity for the CF₃CFHCF₂OCF₂H spectrum is in good agreement with the value of 3.42×10^{-16} cm² molecule⁻¹ cm⁻¹ (620-1450 cm⁻¹) reported by Oyaro et al.⁸ There are no literature data for CF₃CFHCF₂OCF₃ to compare with our result.

Using the method outlined by Pinnock et al.,¹⁸ the IR spectra of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H shown in Figure 5, and the IR spectrum of CFC-11 reported elsewhere,¹⁹ we calculate instantaneous forcings for CF3CFHCF2OCF3, CF3-CFHCF₂OCF₂H, and CFC-11 of 0.48, 0.51, and 0.26 W m⁻² ppb^{-1} , respectively. It is of interest to note that, while the integrated absorption intensity of CF3CFHCF2OCF3 is 18% greater than that of CF3CFHCF2OCF2H, the instantaneous forcing of CF₃CFHCF₂OCF₃ is 6% less than that of CF₃-CFHCF₂OCF₂H. This is explained by the fact that a greater proportion (72%) of the absorption by CF₃CFHCF₂OCF₂H lies in the atmospheric window region (approximately $8-12 \ \mu m$, $800-1250 \text{ cm}^{-1}$). This same region only accounts for 55% of the absorption by CF₃CFHCF₂OCF₃. Values of the GWP (global warming potential) for CF₃CFHCF₂OCF₃ and CF₃CFHCF₂-OCF₂H (relative to CFC-11) can then be estimated using the expression²⁰

$$GWP_{HFE} = \left(\frac{IF_{HFE}}{IF_{CFC-11}}\right) \left(\frac{\tau_{HFE}M_{CFC-11}}{\tau_{CFC-11}M_{HFE}}\right) \left(\frac{1 - \exp(-t/\tau_{HFE})}{1 - \exp(-t/\tau_{CFC-11})}\right)$$

where IF_{HFE}, IF_{CFC-11}, M_{HFE}, M_{CFC-11}, τ_{HPE} , and τ_{CFC-11} are the instantaneous forcings, molecular weights, and atmospheric lifetimes of HFE and CFC-11 and *t* is the time horizon over which the forcing is integrated. Using τ (CF₃CFHCF₂OCF₃) = 40 years, τ (CF₃CFHCF₂OCF₂H) = 32 years, and τ (CFC-11) = 45 years,²¹ we estimate that the GWPs of CF₃CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H (relative to CFC-11) are 1.05 and 1.14 for a 20-year horizon and 0.98 and 0.94 for a 100-year time horizon, respectively. Relative to CO₂, the GWPs of CFC-11 on 20- and 100-year time horizon are 6300 and 4600.²¹ Hence, relative to CO₂, the GWPs of CF₃CFHCF₂OCF₃ and CF₃-CFHCF₂OCF₂H are 6600 and 7180 for a 20-year horizon and 4530 and 4340 for a 100-year time horizon, respectively.

4. Discussion

A large body of self-consistent data concerning the atmospheric chemistry of CF3CFHCF2OCF3 and CF3CFHCF2OCF2H is presented. The kinetic arguments advanced in section 3.3 suggest that under ambient conditions OH radicals abstract hydrogen from CF₃CFHCF₂- and -CF₂OCF₂H moeities in HFEs and HFCs with rate constants of approximately 1.7 \times 10^{-15} and 4.9×10^{-16} cm³ molecule⁻¹ s⁻¹, respectively. As with all other saturated HFEs,²² the atmospheric lifetime of these compounds is determined by the reaction with OH radicals and is approximately 40 years for CF₃CFHCF₂OCF₃ and 32 years for CF₃CFHCF₂OCF₂H. CF₃CFHCF₂OCF₃ and CF₃CFHCF₂-OCF₂H have global warming potentials (relative to CO₂) of 4530 and 4340 (100-year time horizon), respectively. Atmospheric oxidation of CF3CFHCF2OCF3 and CF3CFHCF2OCF2H gives CF₃C(O)F in a molar yield which is indistinguishable from 100%. The atmospheric fate of CF₃C(O)F is hydrolysis to produce trifluoroacetic acid. The remaining molecular fragments will be oxidized to CO₂ and HF.^{15,22} At the levels anticipated in the environment, the atmospheric oxidation products of CF3-CFHCF₂OCF₃ and CF₃CFHCF₂OCF₂H are not of concern.

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